	From the INTERNATIONAL BUREAU		
PCT	То:		
NOTIFICATION OF THE RECORDING OF A CHANGE (PCT Rule 92bis.1 and Administrative Instructions, Section 422)	KIM, Inhan 6F, Kyungmin B/D #18-3, Jai Dong, Seocho-gu 137-903 Seoul Republic of Korea	mwon-	
Date of mailing (day/month/year) 11 July 2003 (11.07.03)			
Applicant's or agent's file reference PCT00114	IMPORTANT NOTIF	ICATION	
International application No. PCT/KR02/01868	International filing date (day/month/yea 07 October 2002 (07.10.02)		
The following indications appeared on record concerning: The applicant the inventor		n representative	
Name and Address PSK TECH INC. 430-3, Mogok-dong Pyungtaek-City Gyunggi-do 459-040 Republic of Korea	State of Nationality KR Telephone No. +82-31-660-8762	State of Residence KR	
Républic of Korea	Facsimile No. +82-31-665-4520 Teleprinter No.		
2. The International Bureau hereby notifies the applicant that to the person X the name the add		concerning: the residence	
Name and Address PSK INC.	State of Nationality KR	State of Residence KR	
430-3, Mogok-dong Pyungtaek-City Gyunggi-do 459-040 Republic of Korea	Telephone No. +82-31-660-8762 Facsimile No. +82-31-665-4520.		
	Teleprinter No.		
3. Further observations, if necessary:	T PART CLANE WAS READ A		
4. A copy of this notification has been sent to: X the receiving Office the International Searching Authority	the designated Offices the elected Offices co	AND THE PERSON OF THE PERSON O	
the International Preliminary Examining Authority	other:		
The International Bureau of WIPO 34, chemin des Colombettes 1211 Geneva 20, Switzerland Facsimile No. (41-22) 338-70-90	Nathalie Ma	inslet	

Form PCT/IB/306 (March 1994)

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From the INTERNATIONAL PRELIMINARY EXAMINING

Date of mailing (day/month/year) 20 APRIL 2004 (20.04.2004) Applicant's or agent's file reference PCT00114 International application No. International filing date (day/month/year) Priority date(day/month/year) 19 APRIL 2002 (19.04.2002) International Patent Classification (IPC) or both national classification and IPC IPC7 H01L 21/3065 Applicant	To: KIM, Inhan			PCT	
Applicant's or agent's file reference PCT00114 REPLY DUE within 2 menths from the above date of mailing linternational application No. PCT/KR2002/001868 Of OCTOBER 2002 (07.10.2002) International Patent Classification (IPC) or both national classification and IPC IPC7 H01L 21/3065 Applicant PSK INC. et al 1. This written opinion is the first (first, etc.) drawn by this International Preliminary Examining Authority. 2. This opinion contains indications relating to the following items: 1	5th floor, Daerim Bldg., 1695-4 Seocho Seoul 137-883, Republic of Korea	-dong, Seocho-ku,			·
International application No. PCT/KR2002/001868 International filing date (day/month/year) Priority date(day/month/year) PCT/KR2002/001868 O7 OCTOBER 2002 (07.10.2002) 19 APRIL 2002 (19.04.2002) International Patent Classification (IPC) or both national classification and IPC IPC7 H01L 21/3065 Applicant PSK INC. et al PSK INC. et al PSK INC. et al Priority III Priority III Priority III Priority III Non-establishment of opinion with regard to novelty, inventive step and industrial applicability IV Lack of unity of invention PRIOR Reasoned statement under Rule 66.2(a)(ii) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement VI Certain documents cited VII Certain defects in the international application VIII Certain observations on the international application Priority Pr	· · · · · · · · · · · · · · · · · · ·			0 APRIL 2004 (20.04.2004)	
International Patent Classification (IPC) or both national classification and IPC	Applicant's or agent's file reference PCT00114			101111 - 1.0111	
IPC7 H01L 21/3065 Applicant PSK INC. et al 1. This written opinion is the first (first,etc.) drawn by this International Preliminary Examining Authority. 2. This opinion contains indications relating to the following items: 1	International application No. PCT/KR2002/001868	_	· •		
PSK INC. et al 1. This written opinion is the first (first,etc.) drawn by this International Preliminary Examining Authority. 2. This opinion contains indications relating to the following items: 1	·	or both national classification	ation and IPC		
2. This opinion contains indications relating to the following items: I Basis of the opinion II Priority III Non-establishment of opinion with regard to novelty, inventive step and industrial applicability IV Lack of unity of invention V Reasoned statement under Rule 66.2(a)(ii) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement VI Certain documents cited VII Certain defects in the international application VIII Certain observations on the international application 3. The applicant is hereby invited to reply to this opinion. When? See the time limit indicated above. The applicant may, before the expiration of that time limit, request this Authority to grant an extension, see Rule 66.2(d) How? By submitting a written reply, accompanied, where appropriate, by amendments, according to Rule 66.3 For the form and the language of the amendments, see Rules 66.8 and 66.9 Also For an additional opportunity to submit amendments, see Rules 66.4 For an examiner's obligation to consider amendments and/or arguments, seeRule 66.4bis For an informal communication with the examiner, see Rule 66.6 If no reply is filed, the international preliminary examination report will be established on the basis of this opinion.	Applicant PSK INC. et al				
07/100001 2004 (07/00/2001)	2. This opinion contains indications re I Basis of the opinion II Priority III Non-establishment of IV Lack of unity of inve V Reasoned statement u citations and explanat VI Certain documents c VII Certain defects in the VIII Certain observations 3. The applicant is hereby invited to When? See the time limit indic to grant an extension, s How? By submitting a writte For the form and the la Also For an additional oppo For an examiner's oblig For an informal commit If no reply is filed, the internation	lating to the following item opinion with regard to not nation under Rule 66.2(a)(ii) with the ions supporting such states ited the international application on the international application on the international application at the Rule 66.2(d) in reply, accompanied, when nearly, accompanied, when nearly to submit amendments of the ion of the of th	regard to novelty, invertient ation may, before the expiration appropriate, by americs, see Rules 66.8 and 66 ents, see Rule 66.4 leents and/or arguments, er, see Rule 66.6 on report will be established.	d industrial applicability ntive step or industrial applicability; tion of that time limit, request this A ndments, according to Rule 66.3 5.9 seeRule 66.4bis shed on the basis of this opinion.	
	examination report must be establi	Silicu according to Kule 69.	.2 IS: US AUGUST 20	ω ι (υχ.υδ.2υυ4)	

Name and mailing address of the IPEA/KR

-Korean-Intellectual Property Office
920 Dunsan-dong, Seo-gu, Daejeon 302-701,
Republic of Korea

Facsimile No. 82-42-472-7140

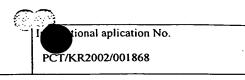
Authorized officer

KIM, Jun Hak

Telephone No. 82-42-481-5785







<u>I. I</u>	Basis (of the op	inion
1.	With	regard to	the elements of the international application:*
	X	the inter	national application as originally filed
		the desc	os originally filed
		pages _	, as originally fried
		pages pages	, filed with the letter of
	_	the clain	ns:
	لــا	pages	, as originally filed
		pages	, as amended (together with any statment) under Article 19
		pages	, filed with the letter of
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		pages pages	, filed with the demand
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			uence listing part of the description:
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2.	the	internations internations in the land	to the language, all the elements marked above were available or furnished to this Authority in the language in which onal application was filed, unless otherwise indicated under this item. ents were available or furnished to this Authority in the following language which is aguage of a translation furnished for the purposes of international search (under Rule 23.1(b)). Inguage of publication of the international application (under Rule 48.3(b)). Inguage of the translation furnished for the purposes of international preliminary examination (under Rules 55.2 and/
3.		wn on the	to any nucleotide and/or amino acid sequence disclosed in the international application, the written opinion was basis of the sequence listing: ned inthe international application in printed form.
	\sqcap		ogether with the international application in computer readable form.
	님		hed subsequently to this Authority in written form.
		The sinterr	hed subsequently to this Authority in computer readable form statement that the subsequently furnished written sequence listing does not go beyond the disclosure in the national applicationas as filed has been furinshed. statement that the information recorded in computer readable form is identical to the written sequence listing has furnished.
4.		The a	mendments have resulted in the cancellation of:
			the description, pages
		\Box	the claims, Nos.
			the drawings,sheet/fig
5.		. ك	
J.			opinion has been drawn as if (some of) the amendments had not been made, since they have been considered to go not the disclosure as filed, as indicated in the Supplemental Box(Rule 70.2(c)).
	-		nt sheets which have been furnished to the receiving Office in response to an invitation under Article 14 are referred to on as "originally filed."

WRITTEN OPINION



V. Reasoned statement under Rule 66.2(a)(ii) with regard to novelty, inventive step or industrial applicability;
citations and explanations supporting such statement

Novelty (N)	Claims	7-9	. Yes
	Claims	1-6	No
Inventive step (IS)	Claims	7-9 -	Yes
	Claims	1-6	No
Industrial applicability (IA)	Claims	1-9	Yes
• • •	Claims		No

2. Citations and explanations

D1: JP 10-135186(22 May 1998)

본원 발명의 청구항 제1항 내지 제6항의 반도체 기판을 고온의 핫 플레이트에서 베이크 실시하고 경화된 포토 레지스트를 애싱 단계에서 팝핑없이 신속하게 제거하여, 웨이퍼의 애싱 공정에 소요되는 시간을 획기적으로 단축함으로써 애싱 처리량을 향상시키고, 종래의 장비를 그대로 사용 가능하며, 10 Torr 이상의 압력 상태에서 실리콘 기판을 핫 플레이트에 올려놓고 소정의시간 동안 베이크를 실시하는 인슈트베이크 단계, 실리콘 기판이 핫 플레이트에 올려놓여져 있는 상태에서 안정한 진공상태를 만드는 진공 단계, 반응챔버에 반응 가스를 선별 주입하는 가스 공정 단계, 포토레지스트가 대부분제거되기까지 플라즈마를 발생시키는 애싱 단계를 포함하는 반도체 웨이퍼애싱 방법에 관한 것이나, 이는 상기 인용예1(D1)에 기재된 플라즈마 발생영역으로부터 시료에 향하여 플라즈마를 하부에 흐르게 하여 시료 위에 이온주입하여 레지스트를 애싱하는 방법으로, 시료를 가열된 시료대로부터 리프트 핀으로 들어올렸던 상태로 애싱한 후 , 시료를 시료대에 원위치하는 애싱 방법으로부터 용이하게 발명할 수 있습니다.